











# **EMERGING TECHNOLOGIES**

## **NEW SKILL NEEDS IN THE FIELD OF NANOTECHNOLOGY**

## International workshop

11-12 July 2005, Stuttgart, Germany

The workshop will discuss the current situation and the development potential of this technology and will focus on approaches and first results to identify of future skill requirements and new emerging occupations in the EU.

## **General information**

Workshop venue	Fraunhofer IAO, Nobelstr. 12, 70569 Stuttgart, Germany
Organisers	European Centre for the Development of Vocational Training (Cedefop) Fraunhofer Institute for Industrial Engineering (Fraunhofer IAO) German Federal Ministry of Education and Research (BMBF) Institut für Strukturpolitik und Wirtschaftsförderung (isw)
No of participants	Max. 50
Target groups	Representatives from policy, social partners, research and business with a particular interest in activities and results in the field of 'Identification of skill needs' in the sector of nanotechnology/new technologies
Working language	English



## Agenda

	Monday, 11 July 2005
08.30-09.00	Registration of participants
	Opening
09.00-09.40	Welcome by organisers:
	Dieter Spath, Fraunhofer IAO, Germany
	Manfred Tessaring, Cedefop Introductory session
	Chairing: <i>Manfred Tessaring</i> , Cedefop
09.40-10.00	Presentation of Skillsnet – Olga Strietska-Ilina, Cedefop
10.00-10.20	Presentation of FreQueNz – Gudrun Steeger, BMBF, Germany
10.20-10.50	<b>Keynote 1:</b> Trends and applications in Nanotechnology and their impact on future skill needs – <i>Daniel Donoval</i> , Nanotech-network in Slovakia, Slovakia
10.50-11.00	Discussion
11.00-11.20	Coffee break
11.20-11.50	<b>Keynote 2:</b> Identification of skill needs in Nanotechnology (overview) <i>Uwe Schumann</i> , isw, Germany
11.50-12.00	Discussion
12.00-12.30	General discussion
12.30-14.00	Lunch
14.00-17.30	Two parallel working groups
	Working group I: Nanotechnology and its effects on skill needs/occupational profiles
	Chairing: Helmut Kuwan, HK-Forschung, Germany
	Report: Uwe Schumann and Henriette Freikamp, isw, Germany
14.00-14.45	Report: <i>Uwe Schumann</i> and <i>Henriette Freikamp</i> , isw, Germany <i>Richard Cutting</i> , Advanced Materials Research Institute, University of Northumbria, United Kingdom
14.00-14.45	<i>Richard Cutting</i> , Advanced Materials Research Institute, University of
14.00-14.45 14.45-15.30	<i>Richard Cutting</i> , Advanced Materials Research Institute, University of Northumbria, United Kingdom
	<ul> <li><i>Richard Cutting</i>, Advanced Materials Research Institute, University of Northumbria, United Kingdom</li> <li>+ questions and answers</li> <li><i>Jan Voves</i>, Department of Microelectronics, Faculty of Electrical Engineering,</li> </ul>
	Richard Cutting, Advanced Materials Research Institute, University of Northumbria, United Kingdom + questions and answers Jan Voves, Department of Microelectronics, Faculty of Electrical Engineering, Czech Technical University, Czech Republic
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14.45-15.30 15.30-16.00	Richard Cutting, Advanced Materials Research Institute, University of Northumbria, United Kingdom + questions and answers Jan Voves, Department of Microelectronics, Faculty of Electrical Engineering, Czech Technical University, Czech Republic + questions and answers Coffee break Grit Petzholdt-Gühne, Schott, Germany + questions and answers
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15.30-16.00	Coffee break
16.00-16.20	Daniel Heubach, Fraunhofer IAO, Germany
	+ questions and answers
16.20-17.30	Final discussion
20.00	Dinner
	Tuesday, 12 July 2005
	Plenary session: Summary of the WG results
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09.00-09.30	Chairing: Alena Zukersteinova, Cedefop

- 09.30-10.00 Summary of the results, working group II Bernd Dworschak, Fraunhofer IAO, Germany
  - + questions and answers
- 10.00-10.30 Conclusions and discussion
- 10.30-11.00 Coffee break

### Final plenary session: Transfer of research results into policy and practice

11.00-11.30 Chairing: Olga Strietska-Ilina, Cedefop

European Nanotechnology Gateway (nanoforum.org) – *Mark Morrison*, Nanoforum, Institute of Nanotechnology, United Kingdom

- + questions and answers
- 11.30-12.00 Future needs of business and the economy *Tim Harper*, Cientifica, Spain
  - + questions and answers
- 12.00-12.30 Final discussion
- 12.30-13.00 Official closing of the workshop



## Parallel sessions description

# Working group 1: Nanotechnology and its effects on skill needs/occupational profiles

The nanotechnology sector has demonstrated the fundamental revolution in a number of technology fields. It is considered to have a very high growth potential and therefore to generate increasing demand for skilled labour. Nanotechnology is a cross-sectoral and highly interdisciplinary field. It penetrates into many industries, such as textile, chemistry, food, medicine, automobile, ICT, environment and many others. Development of nanotechnology brings along a number of totally new tasks, and even jobs and occupations whose requirements have to be identified and transferred into education and training as soon as possible.

This working session will deal with trends and developments in the field of nanotechnology and with their effects on occupational profiles and future skill needs.

The session attempts to answer the following questions:

- What are the trends in the sector of nanotechnology?
- How do these trends affect skill needs and occupational profiles?
- How do these trends affect other specific sectors and activities (and their skill needs and occupational profiles)?

#### Working group 2: Skill shortages and gaps in emerging technologies

Emerging technologies – and nanotechnology is a good example – often initiate high growth for particular sectors and new jobs at different occupational levels (e.g. jobs for researchers and scientists but also for a range of technicians and specialists with secondary, post-secondary and non-university tertiary educational attainment). Moreover, the whole area of new technologies demands a set of basic skills which can be specific or general at different occupational levels and which can promote innovation, research and development (e.g. innovation management). Particular skill gaps and skill shortages may significantly diminish the growth potential and other positive effects of the new technological field.

This working group will discuss different solutions for different levels (enterprises, education and training institutions and systems etc.) as well as experiences from other technological fields and sectors.

The session attempts to answer the following questions:

- How can we identify future skill shortages and gaps in emerging technologies?
- What are specific shortages and gaps already identified/estimated for the nanotechnology sector? What are typical skill shortages and gaps experienced by other newly emerging and fast developing technology sectors? What can the nanotechnology sector learn from these experiences?
- How can skill shortages / skill gaps be tackled and possibly prevented?



### Address of the organisers

### Cedefop/Skillsnet

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### Fraunhofer IAO

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